

Ion energy distribution functions in magnetized and non magnetized radio frequency discharges

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Abstract

The effect of a spatially inhomogeneous static magnetic field on the characteristics of capacitively coupled radio frequency discharges is investigated, with a focus on the sheath dynamics and the energy distribution functions (IEDFs) of the ions impinging the electrodes. Numerical studies are performed with two different kinetic algorithms. The first is a Particle-in-Cell (PIC) code which takes into account the entire discharge; the second is the novel Ensemble-in-Spacetime scheme (EST) which resolves only the sheath. When EST is fed with the sheath voltage and ion flux calculated by PIC, excellent agreement of the IEDFs is found: the applied magnetic field predominantly influences the plasma bulk, i.e., the electron density and the ion flux to the walls; the dynamics of the sheath itself is only indirectly affected. It is concluded that EST may be used as an efficient postprocessing tool to obtain the IEDFs in cases where only simplified (i.e., global or fluiddynamic) information is available.

I. INTRODUCTION

In the past three decades plasma processing such as surface activation, deposition, or etching has become of great importance for a large number of technological applications. With the goal of optimizing plasma processes, several types of plasma sources were been successfully introduced and studied, i.e., hybrid plasma sources, capacitively coupled radio frequency discharges (CCRFDs) driven by more than one frequencies, or magnetized CCRFDs which are used for magnetically enhanced reactive ion etching (MERIE). It has been recently shown that dual frequency CCRFDs which use the electrical asymmetry effect (EAE, [1, 2]) are most suitable to allow for a separate control of the ion flux and energy at substrates (or electrodes), which is one of the main goals in the context of plasma processing. In particular, the ion energy distribution function (IEDF) is one of the most important key parameters [3, 4]. By utilizing the EAE it is possible to invert the electrode functionality, i.e., to change the DC self bias voltage from a large negative value to a large positive value even for geometrically symmetric CCRFDs with the driven electrode area equal to the grounded area. It has been further shown that geometrically asymmetric CCRFDs (small driven electrode and large grounded area, or vice versa), which produce a natural DC self bias voltage, can be completely symmetrized, in the sense that the natural DC self bias voltage can be completely compensated [5, 6].

In this work we study the effect of an externally imposed static magnetic field in combination with the EAE on the characteristics of dual frequency CCRFDs. We focus on the sheath dynamics and the IEDF at the electrodes. In contrast to the MERIE concept where usually a spatially homogeneous magnetic field is applied [7–11], we investigate the case of a spatially *inhomogeneous* magnetic field [12], which is able to (over-)compensate or even to amplify the EAE.

The manuscript is organized as follows. After a short introduction of the discharge configuration and the operation regime, a short review of the employed numerical schemes, namely a one-dimensional Particle-in-Cell algorithm using Monte-Carlo collisions (PIC) and the Ensemble-in-Spacetime scheme (EST), is presented [13]. We discuss the simulation results for different magnetic field configurations focussing on the sheath dynamics and the IEDFs. We conclude that EST may be used as an efficient postprocessing tool to obtain the IEDFs in cases where only simplified (i.e., global or fluiddynamic) information is available.

II. DISCHARGE SETUP

In magnetized discharges (e.g., MERIE discharges) often a slowly rotating static and usually spatially homogeneous magnetic field is applied, with the goal to obtain a high electron density at very low gas pressures in the Pascal or even in the sub-Pascal range. The spatial dimensions of such discharges are typically of the order of a few centimeters, and the magnetic field strength can vary up to tens of mT. Under such conditions the electrons are magnetically confined while ions are not. The applied magnetic field predominantly influences the plasma bulk, i.e., the electron density and the ion flux to the walls, since the electrons suffer an increased number of collisions. It is important to note that the magnetic field does not affect the ion motion within the sheaths. Because of their large mass the Larmor radius for the ions r_L is large compared with the typical length scales of the system. One can easily obtain a ratio of r_L and the sheath width s of $r_L/s = \omega_{pi}/\Omega_i \sim 100$. Here ω_{pi} and Ω_i are the ion plasma frequency and the ion cyclotron frequency, respectively.

In this work we investigate the discharge configuration depicted in figure 1. In a geometrically symmetric plane electrode setup, with an electrode gap of $L = 5$ cm, an external magnetic field is applied near the left electrode. Within a small corridor (indicated by the dashed lines) the magnetic field can be considered parallel to the electrodes along the x -direction. In contrast to MERIE setups where the magnetic field is spatially homogeneous, it is here assumed to decay from the left electrode into the plasma as

$$\vec{B} = \frac{B_0 \hat{x}}{1 + (z/l_B)^2}. \quad (1)$$

The magnetic field amplitude is chosen to be $B_0 = 6$ mT and the decay length is $l_B = 5$ mm. The profile of $B_x(z)$ within the corridor is shown in figure 2.

Further clarification is required to argue that the chosen one-dimensional approach in conjunction with the applied inhomogeneous magnetic field does not contradict Maxwell's equations. As mentioned above we use a one-dimensional approach in z -direction to describe the discharge and apply a static magnetic field directed in the x -direction. If we assume that the magnetic field induced by the plasma current is negligible, Ampere's law given by $\nabla \times \vec{B} = \mu_0 \vec{j}$ requires

$$\frac{\partial B_x}{\partial z} = \frac{\partial B_z}{\partial x}. \quad (2)$$

This necessarily leads to a physical magnetic field configuration as shown in figure 1. This two-dimensional field configuration is similar to that of a “half magnetron”. Such a discharge has of course to be treated by means of at least a two-dimensional simulation approach. However, in this work we assume that the discharge can be described by a one-dimensional model. Such a simplified approach captures the essential physics because within the small corridor (indicated by the dashed line in figure 1) the magnetic field lines are almost perfectly parallel to the electrodes. The steady state current in this configuration is therefore almost completely perpendicular to the electrodes so that the one-dimensional approach is justified.

In order to allow for the EAE a driving voltage $V(t)$ of two consecutive harmonics, i.e., $V(t) = 250 \text{ V} (\sin(2\pi \times 13.56 \text{ MHz } t + \Delta\varphi) + \sin(4\pi \times 13.56 \text{ MHz } t))$, is connected through a blocking capacitor of $C_B = 1.5 \text{ nF}$ to the left electrode. The relative phase $\Delta\varphi$ between the two harmonics is the control parameter for the EAE and varies between $\Delta\varphi = [-\pi/4, \pi/4]$. The right electrode is grounded. The pressure of the background Argon gas is fixed at $p = 1 \text{ Pa}$.

III. NUMERICAL ANALYSIS

To analyze the magnetized (and non-magnetized) CCRFD described above, we employ two conceptually different kinetic approaches. The first is an explicit electrostatic 1d3v PIC code (see e.g., [14]). Within a single PIC cycle (cf. figure 3) the Poisson solver, the particle pusher and the Monte-Carlo collision module are successively iterated until convergence of the overall simulation is achieved. To couple the different modules, a first order field interpolation and charge assignment is performed. The particles are moved according to the Lorentz force using a push algorithm based on Boris' approach [15]. Collisions of electrons and ions with the fixed background gas are performed in the frame of a slightly modified null-collisions method [16], with respect to the classical method proposed by Skullerud [17]. Since Argon is used as the background gas the collision processes include elastic scattering of both electrons and ions, ionization and excitation due to electron collisions, and backward scattering (i.e., charge exchange collisions) of ions. Cross-section data are taken from Phelps et al. and the LXCat Database [18, 19].

The second approach relies on EST which resolves only the sheath, unlike PIC which treats the entire discharge. EST is an iterative algorithm based on the solution of a set of kinetic equations for the ions, Boltzmann's relation for the electrons, and Poisson's equation for the electric field. Similar to PIC, EST employs the null-collision method to account for elastic and charge exchange collisions of ions, but does not take into account ionization and excitation processes. EST is fed by two input parameters: the first is the ion flux given at the sheath edge. The second is the sheath voltage which can have an arbitrary periodic waveform. Because of its efficient convergence behavior, EST allows for fast and kinetically self-consistent simulations of sheaths of CCRFDs. More details concerning the mathematical description and the validation of the model can be found in [13].

In order to compare the results of the two different approaches, we extract the ion flux and the sheath voltage from the PIC simulations. For this we calculate the sheath width $s(t)$ using the definition [20]

$$\int_0^{s(t)} n_i dx = \int_{s(t)}^{\infty} (n_i - n_e) dx. \quad (3)$$

Ion flux and sheath voltage are then used as input parameters for EST.

IV. RESULTS AND DISCUSSION

A. Magnetized CCRFD

We start our analysis by comparing two different discharge scenarios, without (case I) and with (case II) an applied static magnetic field at the left electrode by means of PIC simulations. The simulation parameters are specified in section II. The relative phase between the two driving voltages is set to $\Delta\varphi = 0$. Figure 4 shows the space time dynamics of the electron densities for the two different cases. For case I we obtain, as expected, a symmetric density profile and a symmetric sheath dynamics. In contrast, in case II the discharge shows a significant asymmetry due to the applied magnetic field. One can observe that the magnetized sheath in front of the left driven electrode is much smaller than the non-magnetized sheath in front of the right grounded electrode. This asymmetry can also be seen in figure 5 where the (time-averaged) ion density profiles are shown. It is clearly visible that the maximum is shifted and the slope is steeper towards the magnetized region in front of the left electrode. This asymmetry in the electro density (and the ion flux) is the reason the different sheath widths. Figure 6 compares the temporal behavior of the sheath widths for the two different cases of both the left (driven) and right (grounded) sheath. While in case I both sheaths show very similar oscillations, in case II the magnetized sheath is on average significantly smaller than the non-magnetized sheath (right). One can clearly observe a total collapse of the magnetized sheath at 10 ns. This magnetically induced asymmetry results in a substantial DC self bias voltage (of about 130 V). This can be seen in figure 7, where the time-averaged potential profiles for the two different cases are compared.

Due to the high ion mass and a relatively low ion velocity, the magnetic field in front of the left electrode is not able to significantly confine the ions. The main effect introduced by the external magnetic field is the efficient electron heating near the left sheath. One can observe a locally increased plasma density and an increased ion flux to the electrode. Therefore, despite the magnetic field, we attribute the differences in the energy distribution functions of ions impinging the electrodes (cf. figure 8) mainly to the different plasma density profiles (thus the ion flux towards the electrodes) and to the sheath voltages accelerating the ions. The validity of this hypothesis is verified in section IV C, where IEDFs are calculated using the non-magnetic EST model. (Note that despite of the geometric and electric symmetry

of case I, one may observe a small asymmetry in the sheath potentials and therefore the IEDFs. The reason for this is the difference of the sheath expansion and the resulting beams of energetic electrons caused by the corresponding electric fields in the sheaths. This effect has been previously reported by Schulze et al. [21]).

B. Magnetized CCRFD with Electrical Asymmetry

The parameter which controls the EAE is the relative phase between the two driving voltages $\Delta\varphi = 0$. By introducing a spatially inhomogeneous magnetic field, which itself produces an asymmetry, one is able to amplify or (over-)compensate the EAE. As an example, we compare the previously discussed PIC results for case II with the results obtained for the same discharge conditions, but for relative phases of $\Delta\varphi = \pm\pi/4$ instead of $\Delta\varphi = 0$. Figure 9 shows the IEDFs for this scenario. Comparing the cases (cf. also figure 8) one can observe that for $\Delta\varphi = -\pi/4$ the EAE can be used to amplify the magnetically induced asymmetry (in terms of the ion bombardment energy). Using a relative phase of $\Delta\varphi = \pi/4$ leads to an over-compensation of the magnetically induced asymmetry.

C. EST: Magnetic Field Influence

We have claimed above that the magnetic field does not significantly influence the dynamics of the sheaths and thus plays only a minor role when calculating IEDFs. To justify this hypothesis we analyze the sheath dynamics using EST, which does not include any magnetic field effects. For this purpose we compare the IEDFs for the two cases without magnetic field (case I) and with magnetic field (case II) obtained by PIC with the results from EST. As described in section III we extract the ion flux and the sheath voltage from the PIC simulation and use then as input parameters for EST.

Figure 10 shows the space time dynamics of the electron density for both simulation approaches for case II (magnetized case for $\Delta\varphi = 0$). The sheath dynamics is in very good qualitative agreement. Deviations can be observed particularly only near the sheath edge. This deviation is attributed to the different collision models used in PIC and EST: The latter does not account for ionization and excitation processes, while the PIC simulations allows for both ionization and excitation, and therefore efficient plasma generation.

178 A second reason (which has to be proofed) is nonlinear electron resonance heating due
179 to the excitation of higher harmonics in the plasma current and thus the plasma series
180 resonance [22–25]. The higher harmonics are clearly visible in the sheath dynamics. Of
181 course, this nonlinear sheath bulk interaction is not included in EST results, since EST
182 resolves one sheath only.

183 Figure 11 compares the IEDFs for the unmagnetized case I obtained using both PIC and
184 EST. It is evident that both models are in excellent agreement. We can therefore conclude
185 that it is well justified to use the “non-magnetic” EST for studying the effect of the magnetic
186 field on IEDFs. Figure 12 shows the IEDF for the magnetized case II. The results are again
187 obtained using both PIC and EST. Also for this case the results are in excellent agreement.
188 Only minor deviations can be observed when comparing the magnitudes of the double peak
189 structure. It is important to note that EST yields the same IEDFs as PIC, regardless of
190 whether the discharge is magnetized or non-magnetized. The reason is, that both the sheath
191 dynamics and the ion motion in the sheath are mainly driven by the electric field, and only
192 weakly affected by the magnetic field.

V. CONCLUSIONS

In this work we analyze the effect of a spatially inhomogeneous static magnetic field on the characteristics of capacitively coupled radio frequency discharges, with a focus on the energy distribution function (IEDF) of the ions impinging the electrodes and the sheath dynamics. By means of a one-dimensional Particle-in-Cell algorithm using Monte-Carlo collisions (PIC) we show that geometrically symmetric capacitively coupled radio frequency discharges can be asymmetrized by applying a spatially inhomogeneous static magnetic field. This magnetically induced effect is similar to the electrical asymmetry effect (EAE). We further show that the EAE can be amplified or (over-)compensated.

We find that the novel Ensemble-in-Space time scheme (EST) which resolves the sheath only, is able to provide IEDFs almost equal to the ones obtained from the fully self-consistent PIC simulation. Furthermore, we find an excellent agreement of the two models for both cases, the non-magnetized and the magnetized case. We conclude that EST may be used as an efficient postprocessing tool to obtain the IEDFs in cases where only simplified (i.e., not kinetic) information is available. Since EST allows for an arbitrary number of ion species, pressure, and composition of the background gas, it is a viable tool for the technology oriented computer aided design (TCAD) of realistic plasma processes [26].

Since the proposed discharge configuration is rather complex, a two-dimensional analysis of this problem is being performed and will be published elsewhere. Furthermore, the complex heating mechanisms of the magnetized CCRFDs due to the field-particle interaction are of great interest and require a further analysis which is beyond the scope of this paper.

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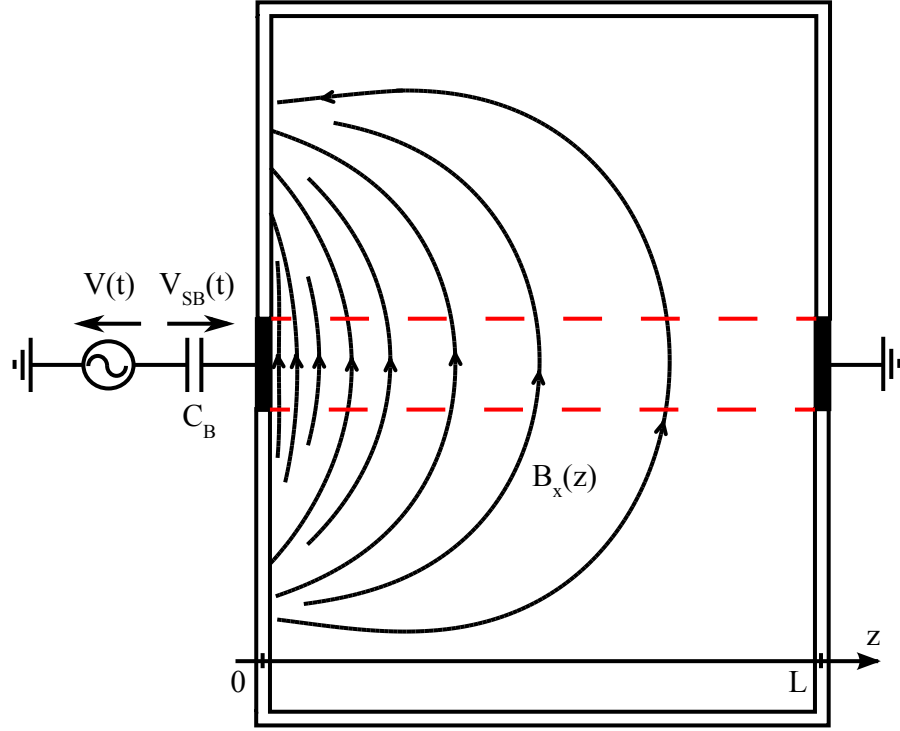


FIG. 1. Schematic of the discharge configuration. A static magnetic field is assumed at the left electrode which falls off along the z axis according to (1). There are two symmetric electrodes and the plasma is confined by a dielectric wall. The dashed lines indicate the region of interest for this work.

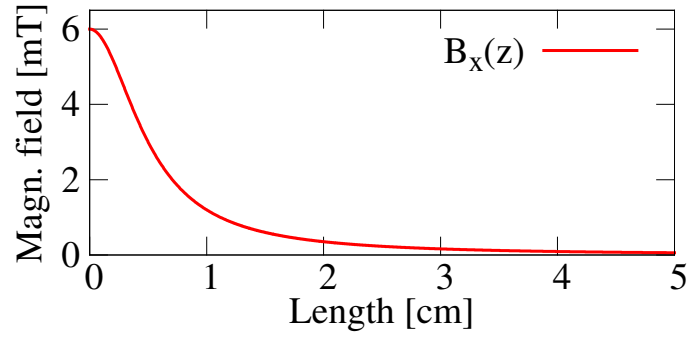


FIG. 2. Magnetic field profile inside the discharge.

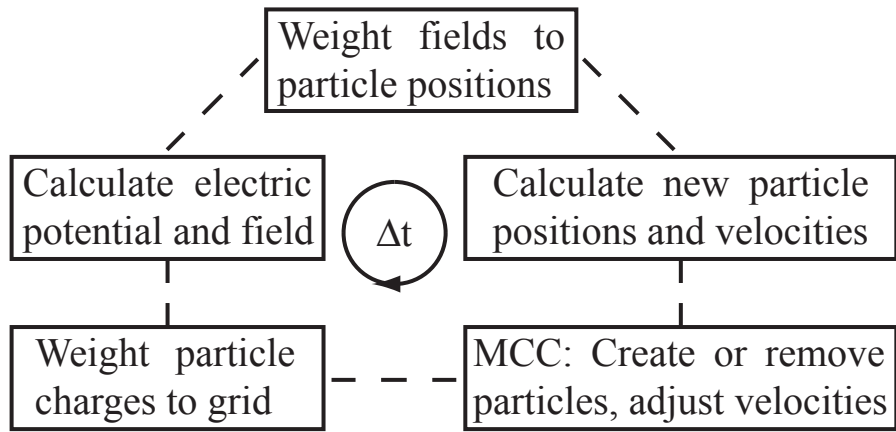


FIG. 3. Iteration scheme of the Particle-in-Cell algorithm.

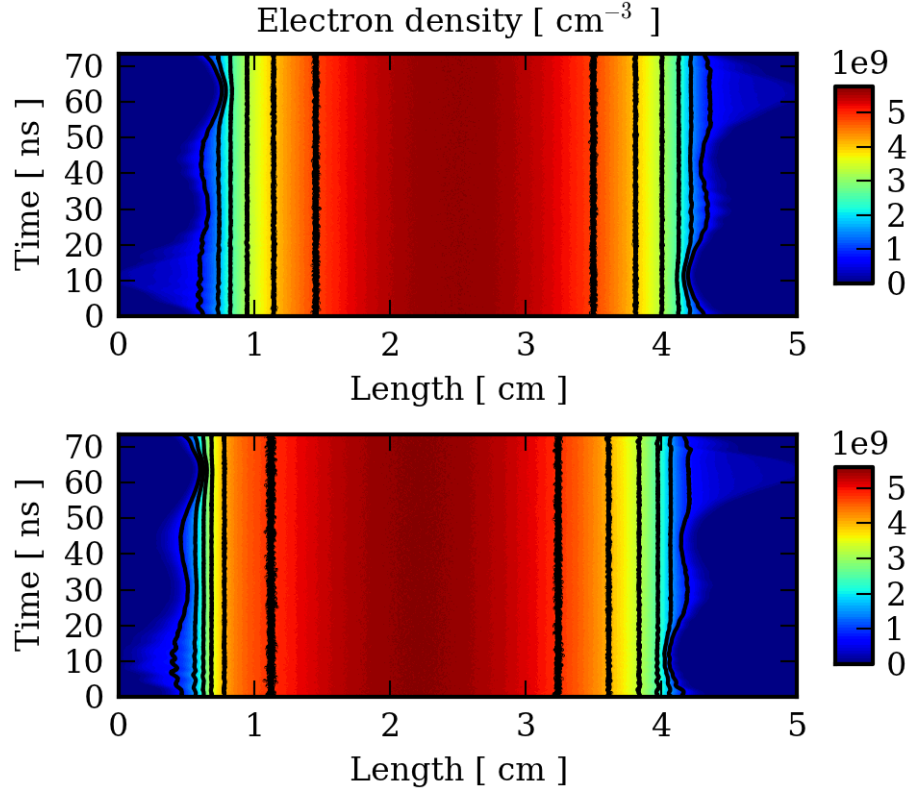


FIG. 4. Electron density obtained using the PIC method without (top, case I) and with (bottom, case II) an external magnetic field.

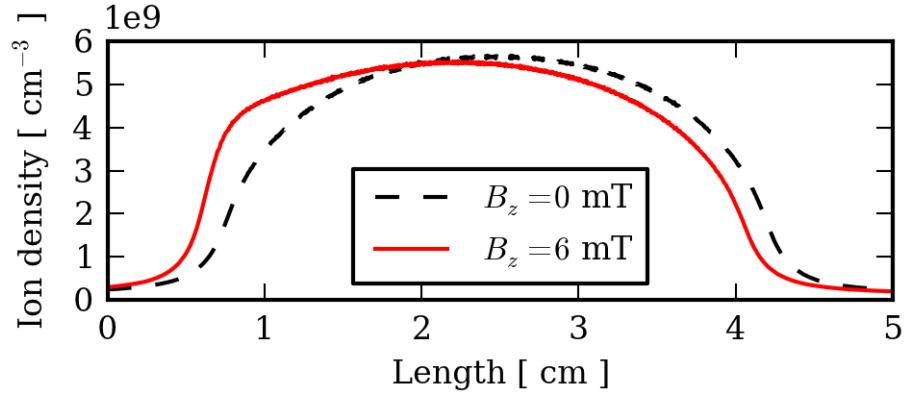


FIG. 5. Time-averaged ion density without (dashed, case I) and with (solid, case II) magnetic field. The maximum is shifted to the left towards the magnetized plasma sheath.

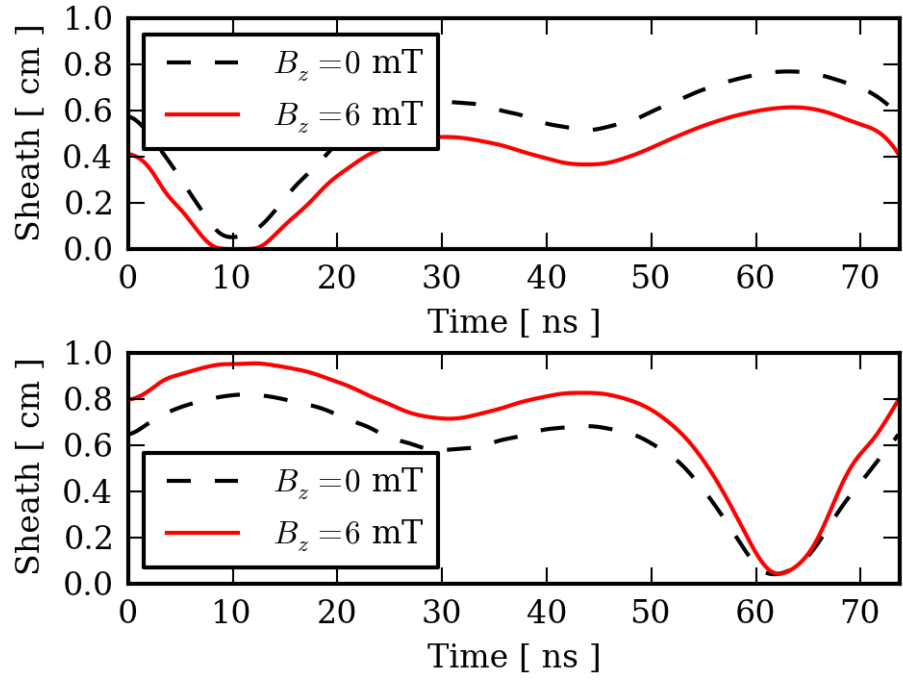


FIG. 6. Sheath modulation $s(t)$ (non-magnetized and magnetized case, respectively) for the left (top) and the right plasma boundary sheath (bottom).

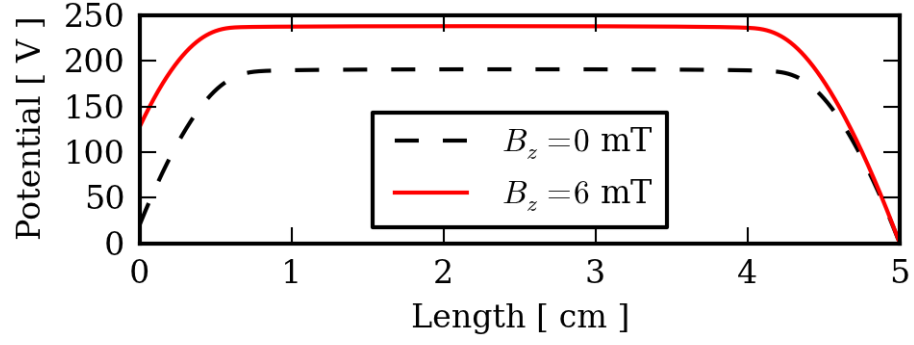


FIG. 7. Time-averaged potential along the discharge without (dashed, case I) and with (solid, case II) magnetic field. Due to the magnetic field a strong dc self-bias is established leading to a high ion bombardment energy (cf. also figure 8).

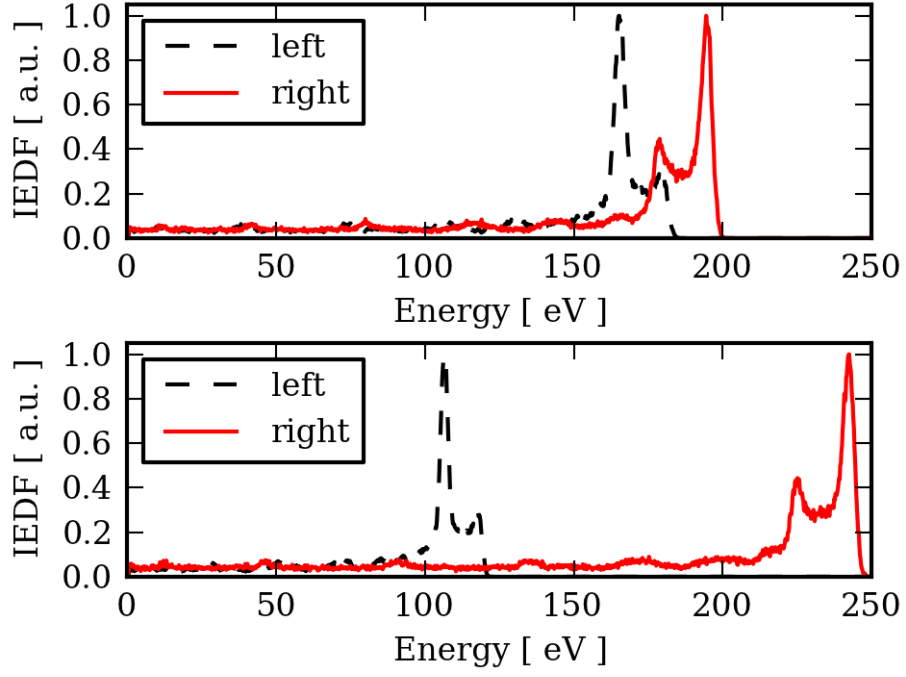


FIG. 8. IEDFs for the two cases without (top, case I) and with (bottom, case II) an external magnetic field. With a magnetic field the discharge is strongly asymmetric. This is also detectable in the resulting IEDFs.

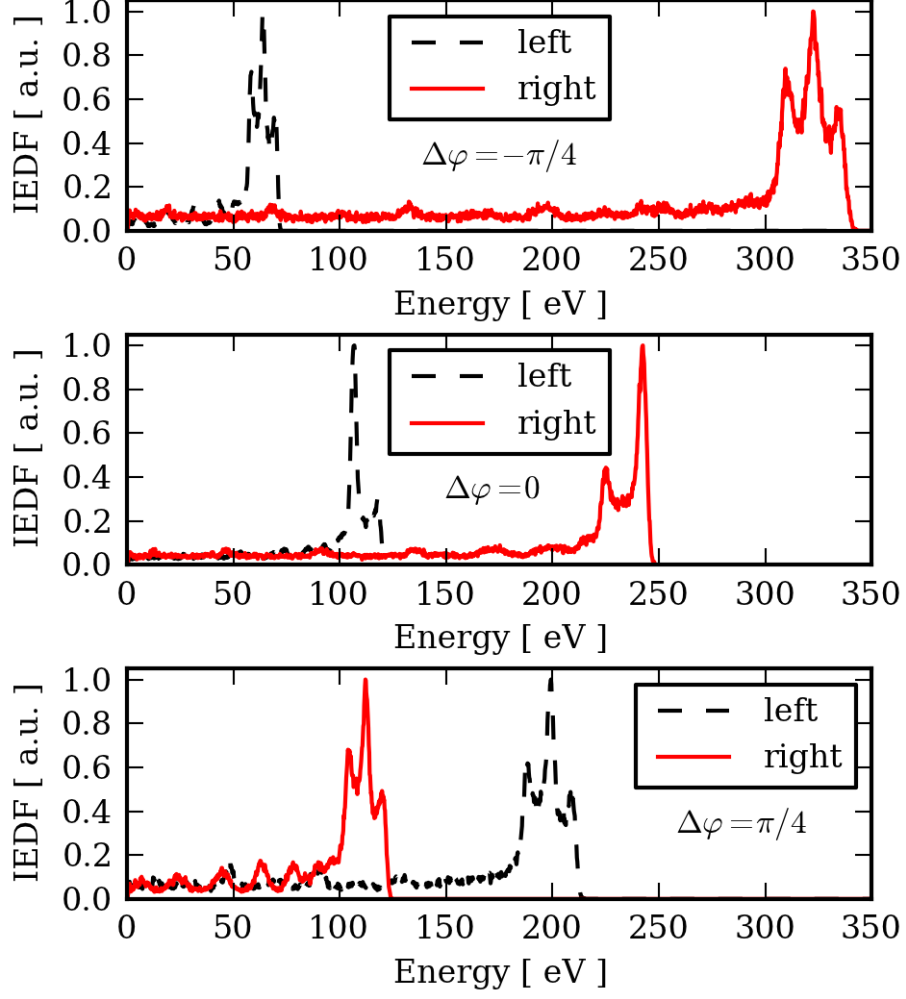


FIG. 9. IEDFs for the magnetized case for different relative phases of $\Delta\varphi$. The magnetically induced asymmetry ($\Delta\varphi = 0$, middle) can be clearly amplified ($\Delta\varphi = -\pi/4$, top) and also over-compensated ($\Delta\varphi = \pi/4$, bottom) using the EAE.

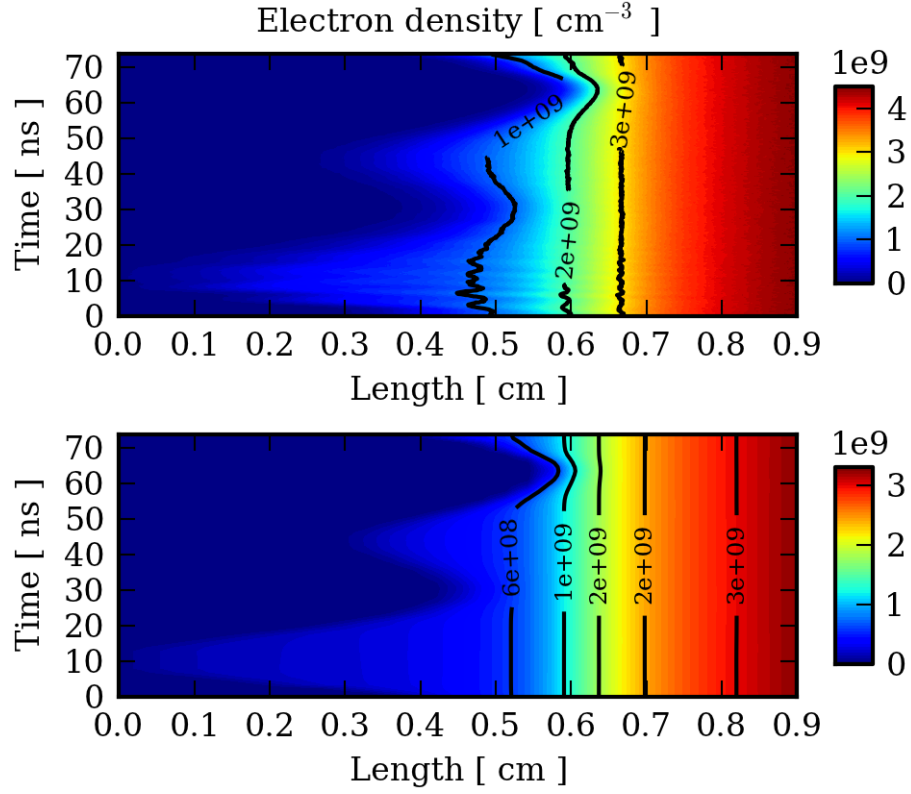


FIG. 10. Electron density in the left sheath region obtained with the PIC method (top) and the EST model (bottom) for the magnetized case (case II). Despite the discrepancy in magnitude, there is good qualitative agreement regarding the sheath dynamics.

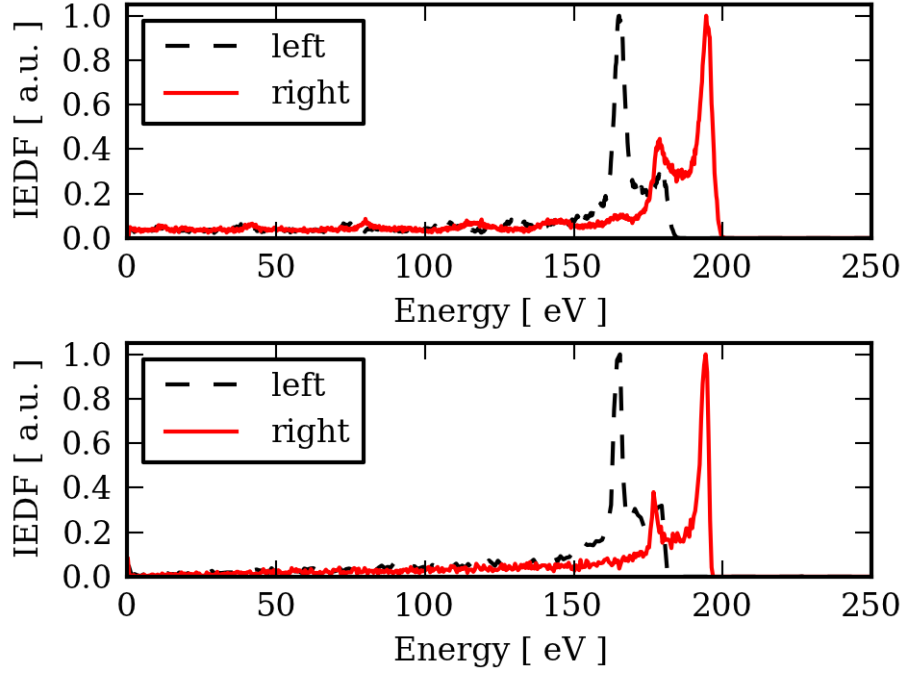


FIG. 11. IEDFs obtained for the non-magnetized case (case I) and $\Delta\varphi = 0$ using the PIC (top) and the EST model (bottom). There is excellent agreement between both models in the non-magnetized scenario.

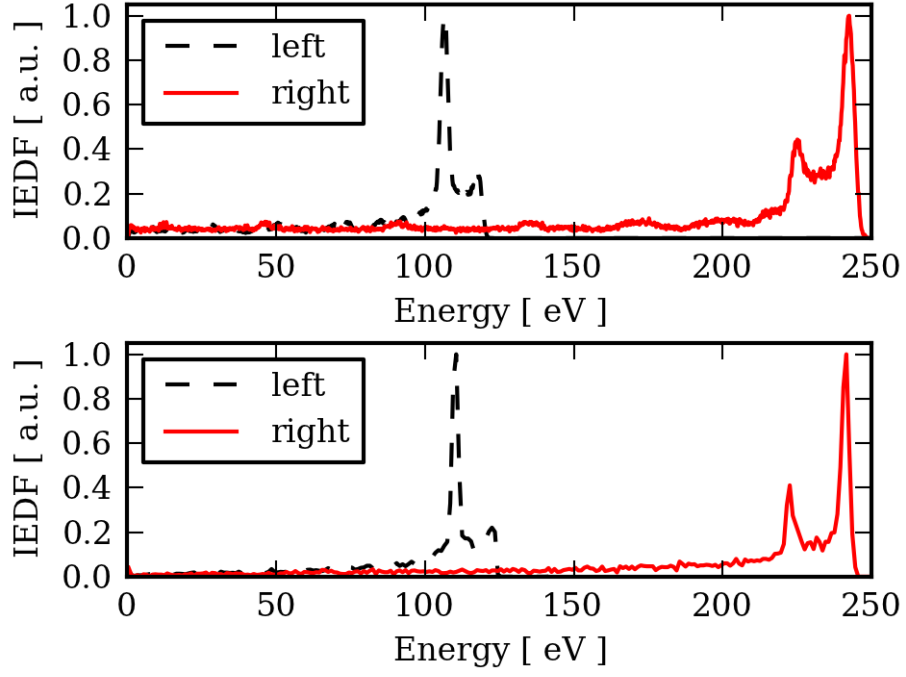


FIG. 12. IEDFs for the magnetized case (case II) and $\Delta\varphi = 0$. The PIC simulation (top) is performed with a constant inhomogeneous magnetic field, while the EST model (bottom) does not explicitly include the magnetic field, but is fed with input data obtained from the magnetic PIC simulations.